Organiser:



Co-organisers:











CILTHK Two-day Course 2018 Practical Considerations in Arbitration

Date: 8-9 Dec 2018 (Sat & Sun)

Time: 9:30am – 5:40pm (Registration starts at 9:00am) **Venue**: V322, 3/F, Jockey Club Innovation Tower (Block V)

The Hong Kong Polytechnic University

Fee: • CILTHK Member:

Free

(Deposit HK\$500, refundable upon attendance of at least 3 sessions)

• Non-CILTHK Member:

Free

(Deposit HK\$500, refundable upon attendance of at least 3 sessions;

For issuing of a **CILTHK** CPD/attendance

certificate, an administration fee HK\$100.00/certificate is required)

Quota: 280 Medium: Cantonese

CPD: 160 points Registration 23 Nov 2018

Deadline: 23 Nov 2018

Program:

Day I – 8 December 2018 (Sat)	
09:00	Registration
Session I	
09:30 - 09:45	Welcome Address & Presentation of Souvenir
09:45 – 11:00	Obtaining security for your claims
11:00 – 11:20	Tea Break
11:20 – 12:15	Obtaining security for your claims
12:15 – 14:30	Lunch
Session II	
14:30 – 15:45	Practical considerations in multi-party dispute with particular focus on NEC & FIDIC contracts
15:45 – 16:00	Break
16:00 – 17:15 17:15 – 17:40	Law concerning international commercial arbitration Q & A
17:40	End

Day II – 9 December 2018 (Sun)	
09:00	Registration
Session III	
09:45 – 11:00	Controlling costs and efficient management of arbitration
11:00 – 11:20	Tea Break
11:20 – 12:35	Third-party funding and its related problems
12:35 – 14:30	Lunch
Session IV	
14:30 – 15:45	Some real-life examples in relation to expert evidence
15:45 – 16:00	Break
16:00 – 17:40	Q & A
17:40	End
	Distribution of deposit cheque and CPD certificate for those attendees who have achieved 75% or above attendance.
	 CPD certificate will be issued by CILTHK, HKARMS, HKIE-LTD, ImechE(HK) IPSHK respectively to their registered members ONLY. For HKIE members, 100% attendance is required.
	2) <u>CILTHK</u> CPD certificate for <u>non-CILTHK members</u> will only be issued for an administrative fee of HK\$100.

CILTHK Two-day Course 2018

Speakers' Profiles



Mr. Philip Yang – Maritime & Commercial Arbitrator. Deputy Chairman of the Baltic International Maritime Council (BIMCO) Documentary Committee, Honorary Chairman of Hong Kong International Arbitration Centre, Past President of Asia Pacific Regional Arbitration Group, Chartered Fellow of the Chartered Institute of Logistics and Transport. Chartered Arbitrator.



Prof. Albert Leung – is a Chartered Engineer with over 35 years' experience in civil and structural engineering works. He is currently the Director of Operations at Jacobs China Limited. He has been involved in litigation, arbitration and expert witness works on various engineering projects. Currently he is an adjunct professor at HKU and City University for their Master Courses on arbitration law and practice. He is also an adjunct lecturer at the HKU SPACE postgraduate diploma in construction law and arbitration and the postgraduate diploma in construction law, mediation and arbitration courses. He is also the secretary for the Hong Kong Institution of Engineers Alternative Dispute Resolution Committee and represents the Institution on the HKIAC Appointment Advisory Board and the HKMAAL Mediation Accreditation Committee.



Mr. Danny Mok – Maritime & Commercial Arbitrator. Graduated from the Hong Kong Polytechnic (now the Hong Kong Polytechnic University) in 1991, studied shipping studies in the Nautical Department. Fellowship of the Institute of Chartered Shipbrokers, Member of the Chartered Institute of Arbitrators, Associate Member of the Chartered Insurance Institute, Panel arbitrator of the HKIAC, Member of the Hong Kong Maritime Arbitration Group, Supporting member of the London Maritime Arbitrators Association, Panel arbitrator of the Singapore Chamber of Maritime Arbitration, Member of the Baltic Exchange, Council Member of the HKIAC, Member of the Advisory Committee on Promotion of Arbitration, Department of Justice, HKSAR, Co-author of the Chinese book "Arbitration Law – from the Arbitration Act 1996 to international commercial arbitration" published by the Law Press in China.